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Introduction

The 6th Advanced Laser Technology and Applications Conference (ALTA 2017) is one of the eight conferences in International Conference on Optical Instrument and Technology (OIT 2017) which were held 28–30 October 2017 in Beijing, China. During those days, the conference provided a technical forum for reporting and discussing about the latest research and development in laser science and technologies, as well as its promising applications.

The conference was organized into technical sessions on solid state lasers, fiber lasers and novel lasers, related technologies and applications. Up to 300 presentations to the overall symposium (including 5 invited talks, 25 regular contributions and 24 posters to ALTA 2017) reported the latest achievements in the above fields from all over the world, especially in China. Many remarkable progresses such as: KW high-power all-solid-state quasi-continuous wave laser and their applications, efficient solid-state laser for vortex and vector output, optical field manipulation of random distributed feedback fiber lasers, diode-pumped Kerr-lens mode-locked high power Yb-bulk lasers, and laser patterning technology for the manufacturing of paper-based medical diagnostic devices, etc., attracted wide interesting by participants.

As the chairs of this conference, we would like to express our gratitude to all participants and committee members who contributed to the conference through their presentations and service. We also hope to thank SPIE for editing the Proceedings publication. Without the cooperation and support by all participants and committees, the conference could not have been so successful.

Zhiyi Wei
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Pu Wang
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